UNITED STATES PATENT AND TRADEMARK OFFICE
BEFORE THE PATENT TRIAL AND APPEAL BOARD
——————————————————————————————————————
TECHTRONIC INDUSTRIES CO LTD
Petitioner,

v.

## THE CHAMBERLAIN GROUP, INC. Patent Owner.

Case No. IPR2017-00432

Patent No. 7,339,336

PETITIONER'S REQUEST FOR REFUND OF POST-INSTITUTION FEES



Under the Patent and Trademark Office's Final Rule Setting and Adjusting Patent Fees, 78 Fed. Reg. **4212**, **4233–34** (Jan. 18, 2013), Petitioner requests a refund in the amount of \$14,000 to be paid to Deposit Account No. 50-0310.

On December 6, 2016, Petitioner filed a petition for *inter partes* review ("IPR") in the above-captioned case seeking review of 6 claims of U.S. Patent No. 7,339,336. In accordance with the fee schedule specified in 37 C.F.R. § 42.15(a), Petitioner paid \$23,000 at the time this petition was filed. Petitioner's payment consisted of \$9,000 for the IPR request fee—(\$9,000 for the initial fee)—and a further \$14,000 in post-institution fees—(\$14,000 for the post-institution fee). On May 23, 2017, the Patent Trial and Appeal Board denied institution of review as to all of the challenged claims.

Accordingly, Petitioner requests a refund of \$14,000 for the post-institution fees that it has paid in connection with IPR2017-00432.



Dated: September 29, 2017 Respectfully Submitted,

/ Dion M. Bregman /

Dion M. Bregman Registration No. 45,645

Email: dion.bregman@morganlewis.com MORGAN, LEWIS & BOCKIUS LLP 1400 Page Mill Road

Palo Alto, CA 94304 Telephone: 650.843.4000 Facsimile: 650.843.4001

Attorneys for Petitioner ONE WORLD TECHNOLOGIES, INC., D/B/A TECHTRONIC INDUSTRIES POWER EQUIPMENT



## **CERTIFICATE OF SERVICE**

The undersigned certifies that the foregoing PETITIONER'S REQUEST

FOR REFUND OF POST-INSTITUTION FEES was served on September 29,

2017, via email to Patent Owner's counsel at the following email addresses:

IPR39907-0014IP1@fr.com PTABInbound@fr.com

Dated: September 29, 2017 Respectfully Submitted,

/ Dion M. Bregman /
Dion M. Bregman

Registration No. 45,465

